AMENDMENT Attorney Docket No. Q65755

REMARKS

Entry and consideration of this Amendment is respectfully requested.

Respectfully submitted,

Registration No. 21,092

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RJS/ob

Date: August 7, 2001

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APPENDIX VERSION WITH MARKINGS TO SHOW CHANGES MADE

IN THE CLAIMS:

The claims are amended as follows:

10. A base material comprising:

an organic polymer layer as a first layer formed on a substrate; and a second resist layer formed on said organic polymer layer, said second resist layer being composed of a positive resist composition according to any one of claims 1 to 9 claim 1 and having a thickness of from 50 to 200 nm.